FORM PTO-1449 (SUBSTITUTE) U.S. DEPARTMENT OF COMMERCE				Attorney Docket No.: Applic. No. L&L-10078 09/939,330 CEIVE Applicant Alfred Kersch et al. Filing Date Group Art Unit				
U.S. DEPARTM PATENT AND 1			Applicant Alfred Kersch et al.					
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STATEMENT BY APPLICANT (37 CFR 1.98(b))				Filing Date Group Art Unit August 24, 2001 1762				
		U.S.	PATENT I	DOCUMENTS				
EXAMINER						SUB	FILI	
INITIALS	1	PATENT NO.	04/14/92	PATENTEE Greenwald	CLASS	CLASS	DA	TE
	A	5,104,690	ļ					
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OTH	IER D	OCUMENTS (Incl	uding Auth	nor, Title, Date, Pe	ertinent Pa	ages, etc.)	
	0	L.A. Wills et al.: "Deposition of Ferroelectric Bi ₄ Ti ₃ O ₁₂ Thin Films", Extended Abstracts, Fall Meeting, Seattle, Washington, 90/2, 1990, p. 701, Princeton, NJ, XP-000294124						
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EXAMINER				DATE CONSIDERED				
	ugh cita	citation considered, ation if not in conform to applicant.						